

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Appl. No.: 10/734,660
Applicant: Hajime Nakagawa
Filed: December 15, 2003
Title: PHOTOTHERMOGRAPHIC MATERIAL
Art Unit: 1752
Examiner: Thorl Chea
Docket No.: FS-F03216-01
Cust. No.: 37398

Confirmation No. 7673

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

The present Amendment is responsive to the Office Action of March 23, 2005.

Please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 7 of this paper.

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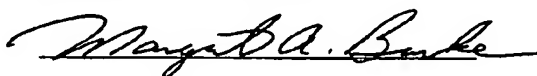
Serial No. 10/734,660

Response to Office action dated March 23, 2005

Claims 6-12 and 21 were rejected under 35 U.S.C. 103(a) as being unpatentable over the combination of Goto, Oya, and Andrews. Once again, Ishigaki is mentioned but not used in the rejection. As set forth above, Goto and Oya do not teach or suggest gelling of the outermost layer of a photothermographic material upon a decrease in temperature. One of ordinary skill in the photothermographic art would not look to Andrews to solve the problem of temperature-dependent decrease in fluidity. Therefore, it is respectfully requested that this rejection be withdrawn.

In view of the foregoing amendments and remarks, it is submitted that all of the claims currently pending in the application are in condition for allowance. Early and favorable action is respectfully requested.

Respectfully submitted,



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